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RESIST REMOVER RR4

Description

 Resist Remover RR41 is a stripping solution designed to remove photoresist from the surface of a substrate.

Properties

Principal solvent	dimethyl sulfoxide
Melting temperature (°C)	18
Appearance	clear liquid
Specific gravity at 25°C (g/cm³)	1.00-1.05
Guaranteed shelf life at 25°C storage (years)	3

Processing

- 1. Pour the solution into a resist stripping tank.
- 2. Heat the solution to 100°C under an exhaust hood.
- 3. Place the resist coated substrate in the solution for 5 minutes.
- 4. Rinse the substrate with deionized water until the water resistivity reaches the prescribed limit.